

Electromagnetic Interference Patterns and Measurement Accuracy in Smart Factory Sensors

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Abstract

The transition toward Industry 4.0 has established smart factories as highly automated, data-driven environments where cyber-physical systems operate in continuous synchronization. At the foundation of these systems are smart sensors, which are expected to deliver high-fidelity measurements to facilitate real-time decision-making, predictive maintenance, and autonomous process control. However, modern industrial environments are characterized by dense arrays of heavy electrical machinery, variable frequency drives, and high-voltage power lines, all of which generate complex electromagnetic interference patterns. This study investigates the direct correlation between specific electromagnetic interference profiles and the resulting degradation in measurement accuracy across industrial sensor networks. By establishing a controlled, full-scale smart factory testbed, we systematically exposed a representative suite of temperature, pressure, and vibration sensors to synthesized and real-world radiated and conducted electromagnetic noise. The research methodology utilized high-frequency data acquisition systems to capture instantaneous signal deviations and long-term measurement drifts. Our findings demonstrate that distinct interference patterns yield highly specific error signatures, challenging the conventional assumption that electromagnetic noise merely induces uniform random variance in sensor outputs. The empirical evidence suggests that specific harmonic frequencies couple with sensor internal analog-to-digital conversion stages, leading to deterministic measurement offsets. These results provide a critical foundation for developing advanced, hardware-agnostic interference mitigation algorithms and robust sensor validation protocols.

Keywords: Smart Factories; Electromagnetic Interference; Sensor Accuracy; Industrial Automation; Cyber-Physical Systems

1. Introduction

1.1 The Paradigm of Industry 4.0 and Smart Factories

The contemporary industrial landscape is undergoing a profound transformation driven by the principles of Industry 4.0, which emphasizes the deep integration of physical machinery with advanced digital networks. Smart factories represent the physical manifestation of this paradigm, serving as highly orchestrated ecosystems where raw materials, production equipment, and finished products continuously exchange information. In these environments, traditional hierarchical control structures are rapidly being replaced by decentralized, distributed architectures where individual nodes possess localized computational capabilities. The success of this cyber-physical integration relies entirely on the continuous stream of high-quality, high-resolution data harvested from the physical environment. As manufacturing processes become increasingly complex and intolerant of deviations, the fundamental reliance on primary sensory data grows exponentially. Consequently, ensuring the absolute integrity of this data from the point of origin to the centralized processing units is a paramount concern for researchers and industrial practitioners alike. The literature extensively documents how digital transformation initiatives falter when the foundational data layer is compromised by environmental factors [1].

1.2 The Criticality of Sensor Accuracy in Automated Environments

Within the architecture of a smart factory, sensors act as the sensory organs of the control system. They are responsible for translating physical phenomena such as temperature fluctuations, fluid pressure variations, and mechanical vibrations into discrete digital signals. These digital signals subsequently feed into complex machine learning models, programmable logic controllers, and supervisory control and data acquisition systems. The accuracy of these measurements is not merely a metric of quality; it is a critical safety and operational parameter. In automated environments, a minor deviation in a pressure reading could lead to the improper mixing of chemical compounds, resulting in catastrophic material failure or significant safety hazards. Similarly, subtle inaccuracies in vibration data can obscure the early warning signs of bearing degradation in rotary machinery, negating the benefits of predictive maintenance algorithms and leading to costly unplanned downtime. High measurement accuracy ensures that control algorithms operate within their designed tolerances,

maintaining process stability and product consistency. However, maintaining this level of accuracy is increasingly challenging as sensors are deployed closer to the physical processes, exposing their sensitive microelectronic components to harsh industrial conditions [2]. Extensive efforts have been made to harden these devices, yet vulnerabilities remain, particularly concerning non-physical environmental stressors [3].

1.3 The Challenge of Electromagnetic Interference

Among the various environmental challenges present in a modern manufacturing facility, electromagnetic interference poses one of the most insidious threats to sensor accuracy. Unlike thermal fluctuations or mechanical shock, which often leave physical evidence or trigger immediate diagnostic alarms, electromagnetic interference can subtly and transiently alter electrical signals without permanently damaging the hardware. A smart factory is inherently an electrically noisy environment. The proliferation of high-power equipment, including variable frequency drives used for motor control, automated guided vehicle charging stations, robotic arc welding arms, and industrial microwave heating systems, creates a dense and highly dynamic electromagnetic spectrum. These devices emit complex patterns of both radiated and conducted electromagnetic noise. When sensitive low-voltage sensor cables are routed through these environments, they inadvertently act as antennas, coupling with the ambient electromagnetic fields. This coupling introduces spurious voltages and currents into the measurement circuits. Despite the widespread use of shielded cables, differential signaling, and digital communication protocols, a significant amount of interference still penetrates the measurement chain, particularly at the analog front-end of the sensor before the signal is digitized. Understanding how these complex interference patterns interact with sensor electronics is critical for modern industrial engineering [4].

1.4 Research Objectives and Scope

The primary objective of this study is to systematically investigate and quantify the relationship between specific electromagnetic interference patterns and the corresponding degradation in sensor measurement accuracy. While previous research has broadly acknowledged the negative impact of electromagnetic noise on industrial communications, there is a distinct lack of empirical literature that directly correlates specific frequency spectra and amplitude modulations of interference with deterministic error profiles in analog-to-digital sensor outputs. This study aims to bridge this gap by conducting rigorous, full-scale validations using industrial-grade sensors in a controlled electromagnetic environment. The scope of the research includes the evaluation of temperature, pressure, and vibration sensors under various profiles of radiated and conducted emissions. By mapping the error signatures generated by specific interference patterns, this research intends to provide actionable insights for improving sensor design, enhancing digital filtering algorithms, and establishing more resilient data validation protocols within smart factory architectures.

2. Literature Review and Background

2.1 Evolution of Smart Sensors in Industrial Environments

The historical trajectory of industrial instrumentation has been characterized by a continuous drive toward higher precision, smaller form factors, and increased functionality. Early industrial sensors were predominantly purely analog devices, relying on simple continuous current or voltage loops, such as the standard four to twenty milliampere current loop, to transmit data to centralized controllers. While robust over long distances, these analog systems were inherently susceptible to signal degradation and lacked diagnostic capabilities. The advent of microelectromechanical systems and integrated microcontrollers ushered in the era of smart sensors. These modern devices incorporate the sensing element, analog signal conditioning, analog-to-digital conversion, and digital communication interfaces within a single compact housing. Smart sensors can perform localized data processing, self-calibration, and condition monitoring, significantly reducing the computational load on centralized servers. Protocols such as IO-Link have standardized the integration of these devices, allowing for bidirectional communication and parameterization. However, the miniaturization of electronic components and the integration of highly sensitive analog-to-digital converters have paradoxically increased the vulnerability of these devices to high-frequency electromagnetic disturbances, a phenomenon that has garnered significant attention in recent automation studies [5].

2.2 Sources and Coupling Mechanisms of Electromagnetic Interference

To effectively study the impact of electromagnetic interference on sensor accuracy, it is essential to understand the fundamental physics of noise generation and propagation in industrial settings. Electromagnetic interference is generally categorized into conducted and radiated emissions. Conducted emissions travel through physical pathways, primarily power supply lines and shared grounding systems. In a factory, large inductive loads, such as electric motors starting and stopping, cause severe voltage dips, spikes, and high-frequency harmonic distortions on the shared power grid. These disturbances can bypass power supply filters and directly affect the sensitive reference voltages within a sensor. Radiated emissions, conversely, propagate through free space as electromagnetic waves. The switching action of insulated-gate bipolar transistors within variable frequency drives generates rapid voltage changes. These rapid changes produce broad-spectrum high-frequency radiated noise.

The coupling of this noise into sensor systems occurs through several mechanisms. Capacitive coupling occurs when varying electric fields induce parasitic currents in adjacent conductors, often seen when low-voltage sensor cables are run parallel to high-voltage power lines. Inductive coupling is driven by changing magnetic fields, which induce unwanted voltages in loop circuits, a common problem near large transformers or welding equipment. Furthermore, the analog front-end of a sensor, which amplifies microvolt-level signals from the physical transducer, is highly susceptible to radio-frequency rectification. In this process, high-frequency electromagnetic waves are unintentionally demodulated by the non-linear characteristics of semiconductor junctions within the operational amplifiers, resulting in a direct current offset that directly corrupts the measurement value. The theoretical foundations of these coupling mechanisms have been established in classical electromagnetics, but their specific manifestations in modern digital sensors remain an active area of investigation [6]. Recent studies emphasize that as sensor bandwidths increase to capture higher resolution transient data, they inadvertently become more receptive to a wider spectrum of ambient noise [7].

3.3 Previous Studies on Sensor Validation and Interference Mitigation

The scientific community has explored various strategies to mitigate the effects of electromagnetic interference in industrial networks. Much of the early literature focused on macroscopic solutions, such as optimizing factory floor layouts to maximize the physical distance between high-power noise sources and sensitive communication nodes. Physical shielding techniques, including the use of braided copper shielding on cables, metallic conduits, and Faraday cages around sensitive equipment, have been extensively documented and form the basis of current industrial installation standards [8]. At the circuit level, researchers have investigated the implementation of passive low-pass filters, ferrite beads, and transient voltage suppressors to protect the input stages of sensor microcontrollers.

More recently, the focus has shifted toward digital mitigation techniques. Advanced digital signal processing algorithms, such as finite impulse response filters and adaptive Kalman filters, are increasingly deployed within the sensor firmware to smooth out noise-induced fluctuations [9]. However, these studies often treat electromagnetic interference as a purely stochastic, Gaussian noise process. While this assumption simplifies mathematical modeling and filter design, it fails to account for the deterministic and highly structured nature of interference generated by repetitive industrial processes, such as the synchronized switching of automated drive systems. Some advanced diagnostic frameworks have attempted to use machine learning to detect anomalies in sensor data, but these models are frequently trained on idealized datasets lacking authentic, interference-induced error profiles. Consequently, when deployed in real-world smart factories, these validation algorithms often struggle to differentiate between a genuine physical process anomaly and an artifact caused by electromagnetic coupling.

2.4 Identified Research Gaps

Despite the extensive body of literature on electromagnetic compatibility and sensor technology, critical gaps remain. The most prominent deficiency is the lack of empirical correlation between specific, characterized electromagnetic interference profiles and the exact nature of the resulting measurement degradation in smart sensors. Most testing protocols, including those mandated by international standardization bodies, are designed merely to ascertain whether a device can survive a burst of interference without permanent failure or loss of communication. They do not rigorously quantify the transient loss of accuracy during the interference event. Furthermore, there is a scarcity of research that examines how complex, multi-source interference patterns commonly found in smart factories affect the internal analog-to-digital conversion processes. Current literature lacks comprehensive datasets that map the frequency and amplitude of industrial noise to the corresponding drift, offset, or variance in the reported measurement values of industrial-grade sensors. This study directly addresses these gaps by providing a highly granular, quantitative analysis of sensor performance under precisely controlled electromagnetic stress conditions.

3. Methodology and Experimental Design

3.1 Experimental Testbed Architecture

To conduct a rigorous investigation into the effects of electromagnetic interference on sensor accuracy, a specialized, full-scale experimental testbed was constructed within a shielded anechoic chamber. The use of an anechoic chamber ensured that the background electromagnetic environment was completely controlled, eliminating unknown variables such as ambient radio broadcasts, cellular networks, and uncharacterized building power fluctuations. The testbed was designed to replicate a typical localized automated process skid found in a smart factory, incorporating fluid pumping, thermal regulation, and mechanical agitation systems.

The architecture of the testbed consisted of three primary zones. The first zone was the interference generation sector, which housed a programmable variable frequency drive, a high-voltage contactor relay matrix to simulate inductive load switching, and a localized radio frequency signal generator connected to a broadband directional antenna. The second zone was the physical process simulation area, comprising a closed-loop pressurized hydraulic pipe system, a precisely controlled thermal bath, and a motor-driven eccentric mass vibrator. This zone provided the highly stable, known physical stimuli required for baseline sensor measurements. The third zone was the data acquisition and monitoring station, located

completely outside the shielded chamber to prevent the measurement equipment itself from being affected by the generated interference.

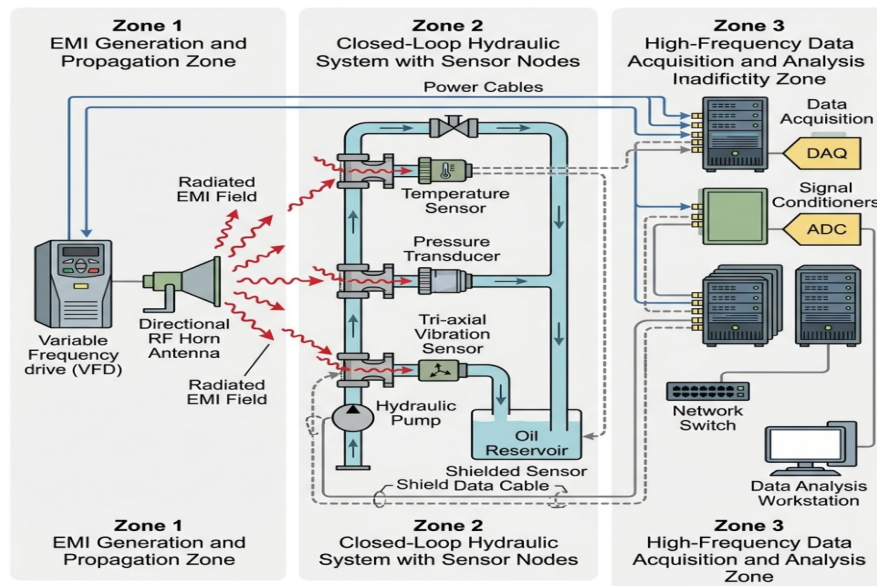


Figure 1: Comprehensive Schematic of the Electromagnetic Interference Sensor Validation Testbed

The physical separation and strict isolation of power and signal grounds between the generation and measurement zones were critical for ensuring that all observed effects were strictly the result of the intended electromagnetic coupling mechanisms. Fiber optic transceivers were utilized to transmit the digital sensor data from the testbed to the external monitoring station, thereby preventing any conducted noise from traveling along the data lines and corrupting the centralized logging servers. The experimental design rigorously adhered to the principles of isolation and repeatability [10].

3.2 Sensor Selection and Profiling

The selection of sensors for this study was carefully curated to represent the most common and critical measurement modalities utilized in modern smart manufacturing processes. Three distinct categories of smart sensors were selected: piezoresistive pressure transmitters, resistance temperature detectors with integrated digital transmitters, and microelectromechanical piezoelectric vibration sensors. To ensure the industrial relevance of the study, all selected devices were commercially available, certified for industrial use, and equipped with standard digital communication interfaces.

Prior to exposure to any electromagnetic interference, each sensor underwent an exhaustive baseline profiling procedure. The purpose of this profiling was to establish the inherent accuracy, precision, and natural noise floor of each device under ideal, electromagnetically quiet conditions. The pressure sensors were calibrated using a deadweight tester to establish a highly accurate reference curve. The temperature sensors were profiled in a precision liquid calibration bath featuring millidegree stability. The vibration sensors were mounted on a reference electrodynamic shaker system driven by a pure sinusoidal signal.

Table 1: Technical Specifications and Baseline Performance of Selected Industrial Sensors

Sensor Category	Measurement Range	Communication Protocol	Baseline Accuracy Deviation	Inherent Noise Floor
Piezoresistive Pressure	Zero to Ten Bar	IO-Link Digital	Zero point zero five percent	Two millibars
Resistance Temperature	Zero to One Hundred Celsius	Standard Industrial Ethernet	Zero point one degrees	Zero point zero two degrees
Piezoelectric Vibration	Zero to Fifty Gravity	Serial Peripheral Interface	Zero point two percent	Zero point zero five gravity

During this profiling phase, the data acquisition systems sampled the sensor outputs at their maximum permissible rates. This high-frequency sampling was necessary to establish the baseline statistical distribution of the measurement data. The baseline data confirmed that, in the absence of external electromagnetic stressors, the selected sensors operated strictly within the manufacturers specified tolerance limits, exhibiting stable, low-variance output signals [11]. The thoroughness of this baseline characterization provided the necessary foundation to confidently attribute any subsequent measurement deviations exclusively to the introduced electromagnetic interference [12].

3.3 Electromagnetic Interference Generation and Control

The generation of electromagnetic interference was managed through a highly deterministic protocol to ensure repeatability across multiple test iterations. The study focused on two primary interference profiles: broadband transient noise and continuous wave harmonic interference.

The broadband transient noise was designed to simulate the effects of heavy industrial switching, such as the actuation of large contactors or automated welding equipment. This was achieved using an electrical fast transient generator coupled directly onto the power supply lines feeding the sensor network. The generator produced rapid bursts of high-voltage spikes, characterized by incredibly fast rise times in the nanosecond range. These fast rise times correspond to a very broad frequency spectrum, effectively stressing the high-frequency rejection capabilities of the sensor power conditioning circuits. The amplitude and repetition frequency of these transients were systematically varied to observe the threshold at which the sensor accuracy began to degrade.

The continuous wave harmonic interference was intended to replicate the radiated emissions typically generated by variable frequency drives and high-power radio frequency industrial equipment. A programmable vector signal generator, connected to a broadband antenna placed at a calibrated distance from the sensor array, was used to sweep a continuous radio frequency signal across a spectrum ranging from one megahertz to one gigahertz. The power level of the transmitted signal was strictly monitored using isotropic field probes to ensure a uniform electromagnetic field strength at the location of the sensors. By sweeping the frequency, the study aimed to identify specific resonant frequencies where the sensor electronics were particularly susceptible to radio frequency rectification, a phenomenon previously theorized but rarely quantified in complex smart sensor assemblies [13].

3.4 Data Acquisition and Error Quantification Procedures

The data acquisition architecture was engineered to capture both the macroscopic digital output of the sensors and, where physically possible, the microscopic analog signals internal to the sensor circuitry. The digital measurement values reported by the sensors via their industrial communication protocols were logged continuously into a time-series database. Simultaneously, highly sensitive differential voltage probes were carefully attached to the internal analog test points of modified reference sensors, specifically monitoring the voltage across the primary sensing element and the input to the analog-to-digital converter. These analog signals were captured using ultra-high-bandwidth digital storage oscilloscopes.

Error quantification was achieved by continuously comparing the values reported by the sensors under electromagnetic stress against the known, stable physical parameters maintained by the process simulation zone. The primary metric for measurement accuracy degradation was defined as the dynamic measurement error, calculated as the absolute difference between the reported sensor value and the true physical value. To account for both instantaneous spikes and long-term offsets, the data was analyzed using multiple statistical techniques. The root mean square error was utilized to evaluate the overall variance and noise introduced into the signal, while the mean bias error was calculated to identify persistent, deterministic offsets caused by interference rectifying into direct current voltages. The time-domain data was supplemented with fast Fourier transform analysis to examine the frequency domain characteristics of the induced errors, allowing for the precise correlation of error frequencies with the known frequencies of the generated interference [14].

4. Data Analysis and Results

4.1 Baseline Performance Under Ideal Conditions

The initial phase of the data analysis involved a rigorous examination of the sensor performance data collected during the baseline profiling under electromagnetically quiet conditions. The statistical distributions of the measurement values were analyzed to establish a benchmark for normal operation. The analysis confirmed that the inherent noise of the sensors followed a standard Gaussian distribution, characterized by zero mean bias and minimal variance. The piezoresistive pressure sensors exhibited exceptional stability, with a constant output precisely matching the reference pressure of the hydraulic system. The digital communication protocols functioned flawlessly, with no dropped packets or transmission errors recorded over an extensive seventy-two-hour continuous testing period. This pristine baseline data was crucial, as it provided absolute certainty that any deviations observed in subsequent tests were entirely attributable to the controlled introduction of electromagnetic interference rather than inherent hardware flaws, thermal drift, or mechanical instability within the testbed apparatus.

4.2 Impact of Conducted and Radiated Emissions on Measurement Accuracy

The introduction of conducted electrical fast transients resulted in immediate and highly observable impacts on the measurement accuracy across all sensor categories, though the manifestation of the errors varied significantly depending on the specific sensor architecture. When subjected to severe high-voltage transient bursts on their power supply lines, the temperature sensors demonstrated a distinct vulnerability in their digital signal processing layers. Rather than producing noisy, fluctuating values, the temperature sensors exhibited intermittent freezing of the output value, followed by sudden, non-physical step changes in the reported temperature. This behavior suggests that the high-frequency transients overwhelmed the internal microcontroller, causing brief execution stalls in the analog-to-digital conversion routine.

Conversely, the radiated continuous wave harmonic interference produced a completely different error signature, primarily affecting the analog front-end of the sensors. As the radio frequency sweep progressed through specific frequency bands, profound deterministic offsets were observed in the pressure and vibration sensor readings.

Table 2: Quantification of Measurement Error Induced by Specific Interference Profiles

Interference Type	Primary Affected Sensor	Error Manifestation	Peak Error Magnitude
Conducted Fast Transients	Temperature Transmitter	Output Value Freezing and Step Jumps	Plus or minus two degrees
Radiated Harmonic Sweep	Pressure Transmitter	Deterministic Direct Current Offset	Plus four percent of full scale
Low Frequency Magnetic	Vibration Sensor	Amplified Sinusoidal Oscillation	Plus or minus ten percent variance

The pressure sensors, in particular, exhibited a severe vulnerability when the radiated frequency matched the resonant frequency of their internal flexible printed circuit boards. At these specific frequencies, the radio frequency energy coupled into the analog amplification circuit and was rectified by the semiconductor components, generating a parasitic direct current voltage. This parasitic voltage was indistinguishable from a legitimate signal generated by the physical pressure transducer. Consequently, the analog-to-digital converter processed this altered voltage, resulting in the sensor reporting a pressure value that was significantly higher than the actual physical pressure in the hydraulic system. This deterministic offset persisted for the entire duration of the specific frequency exposure, completely invalidating the measurement data [15].

4.3 Pattern Recognition in Accuracy Degradation Profiles

A detailed analysis of the high-frequency analog oscilloscope data provided critical insights into the internal mechanisms of the measurement degradation. By correlating the time-stamped digital output errors with the analog signal distortions, distinct pattern recognition profiles could be established. The data revealed that the electromagnetic interference did not simply add random, white noise to the measurement signal. Instead, the interference created highly structured, non-Gaussian error profiles.

For instance, the interference generated by the simulated variable frequency drive produced a complex, multi-tonal noise signature on the internal analog lines of the vibration sensor. The fundamental switching frequency of the drive, along with its specific harmonic multiples, coupled capacitively into the high-impedance piezoelectric measurement circuit. Because the fundamental frequencies of industrial drives often overlap with the lower frequency bands critical for monitoring heavy machinery vibration, the resulting interference effectively masked the true mechanical vibration signals. The internal digital low-pass filters of the sensor were entirely ineffective at mitigating this issue, as the interference frequencies fell squarely within the intended measurement passband of the device. This finding highlights a fundamental limitation in traditional sensor filtering techniques when deployed in dense, modern electromagnetic environments [16].

4.4 Statistical Validation of Interference Models

To mathematically validate the observations, extensive statistical modeling was performed on the aggregated datasets. Analysis of variance techniques were utilized to determine the statistical significance of the various interference parameters, including amplitude, frequency, and coupling mechanism, on the magnitude of the measurement error. The statistical models confirmed, with a high degree of confidence, that the measurement accuracy degradation is a highly non-linear function of both interference frequency and field strength.

Furthermore, regression analysis demonstrated that while strong conducted transients primarily affect the digital integrity and timing of the sensor microcontrollers, radiated high-frequency fields predominantly dictate the continuous analog accuracy. The statistical validation proves that different sources of electromagnetic noise in a smart factory environment require entirely different validation and mitigation strategies. An algorithm designed merely to filter out Gaussian noise will completely fail to correct the deterministic offsets caused by radio frequency rectification. These statistical models provide the necessary empirical framework for developing next-generation, dynamically adaptive sensor validation algorithms that can recognize specific interference signatures and apply appropriate, targeted corrections [17].

5. Discussion and Conclusion

5.1 Interpretation of Key Findings

The empirical results of this study fundamentally challenge the prevalent assumption within industrial automation that electromagnetic interference primarily causes total communication failure or random, easily filterable noise. Instead, the data unequivocally demonstrates that specific patterns of electromagnetic interference couple with sensor microelectronics to produce complex, deterministic measurement errors. The discovery that radiated radio-frequency fields can cause sustained, non-stochastic offsets in pressure readings due to internal circuit rectification is particularly significant. This phenomenon implies that a sensor can appear perfectly functional, maintaining active digital communication and reporting stable values, while simultaneously transmitting highly inaccurate data to the central control systems. For advanced smart

factory applications relying on precise data for automated control and predictive maintenance, these insidious errors represent a critical vulnerability that traditional diagnostic tools are completely unequipped to handle.

5.2 Practical Implications for Smart Factory Deployments

The implications of these findings for the design and deployment of smart factory architectures are substantial. As industrial networks continue to deploy massive numbers of highly sensitive smart sensors in close proximity to complex, electrically noisy automated machinery, the integrity of the data layer cannot be guaranteed by standard cabling and physical shielding alone. Industrial engineers must adopt a more holistic approach to electromagnetic compatibility, recognizing that sensor accuracy is highly dynamic and context-dependent. The study suggests that process control algorithms should not implicitly trust sensor data, regardless of the sophistication of the sensor hardware. Instead, centralized control systems must implement advanced data validation layers capable of cross-referencing multi-modal sensor inputs and identifying the specific signatures of interference-induced errors. Furthermore, the results indicate a pressing need for sensor manufacturers to improve the high-frequency immunity of their analog front-end designs, potentially moving analog-to-digital conversion even closer to the physical transducer element to minimize the exposed length of vulnerable internal traces.

5.3 Limitations of the Current Study

While the experimental methodology was comprehensive, it is important to acknowledge the limitations of the current study. The research was conducted within a highly controlled anechoic chamber, which, while necessary for isolating specific interference mechanisms, does not perfectly replicate the highly reflective, multipath electromagnetic environment of a real-world factory floor filled with metallic structures and moving machinery. Additionally, the study focused on three specific categories of industrial sensors. While these are broadly representative, other sensing technologies, such as optical encoders, ultrasonic flow meters, or capacitive proximity switches, may exhibit entirely different failure modes and error profiles when subjected to the same electromagnetic stressors. Future validation efforts must be scaled to include a wider taxonomy of instrumentation and should eventually transition from the laboratory into active, operational manufacturing environments to capture the true complexity of ambient industrial noise [18].

5.4 Final Conclusions and Future Directions

This comprehensive investigation has successfully linked specific electromagnetic interference patterns to distinct profiles of measurement accuracy degradation in industrial smart sensors. By systematically profiling the impact of both conducted transients and radiated continuous wave interference on temperature, pressure, and vibration sensors, the study has provided vital empirical evidence that electromagnetic noise induces structured, non-Gaussian errors, including deterministic offsets and localized digital processing stalls. These findings emphasize that ensuring data integrity in the Industry 4.0 paradigm requires moving beyond traditional physical shielding and simple noise filtering. Future research must focus on leveraging these identified error signatures to develop intelligent, hardware-agnostic machine learning algorithms capable of real-time interference detection and dynamic signal correction. Only by developing resilient systems that can autonomously validate their own data under extreme electromagnetic duress can the full potential of fully automated, data-driven smart factories be safely and reliably realized.

References

1. Sun, K.; Yang, J.; Li, J.; Yang, B.; Ding, S. Proximal Policy Optimization-Based Hierarchical Decision-Making Mechanism for Resource Allocation Optimization in UAV Networks. *Electronics* 2025, 14, 747.
2. Yang, Q.; Liu, Y.; Chen, T.; Tong, Y. Federated Machine Learning: Concept and Applications. *ACM Trans. Intell. Syst. Technol.* 2019, 10, 1–19.
3. Molotch, H. The city as a growth machine: Toward a political economy of place. *Am. J. Sociol.* 1976, 82, 309–332.
4. Goel, A.; Masurkar, S.; Pathade, G.R. An Overview of Digital Transformation and Environmental Sustainability: Threats, Opportunities, and Solutions. *Sustainability* 2024, 16, 11079.
5. Kim, J.; Fram, M.S. Profiles of choice: Parents' patterns of priority in child care decision-making. *Early Child. Res. Q.* 2009, 24, 77–91.
6. Ghomri, B.I.-D.; Bendimerad, M.Y.; Bendimerad, F.T. DRL-Driven Optimization for Energy Efficiency and Fairness in NOMA-UAV Networks. *IEEE Commun. Lett.* 2024, 28, 1048–1052.
7. Chaudhary, S.; Budhiraja, I.; Chaudhary, R.; Garg, S.; Choi, B.J.; Alrashoud, M. Proximal Policy Optimization Based Sum Rate Maximization Scheme for STAR-RIS-Assisted Vehicular Networks Underlying UAV. *Alex. Eng. J.* 2025, 118, 700–710.
8. Katz-Sidlow, R.J.; Lindenbaum, Y.; Sidlow, R. Residents' attitudes toward a smartphone policy for inpatient attending rounds. *J. Hosp. Med.* 2013, 8, 541–542.
9. Khanna, S., Ball, J., Alperin, J. P., & Willinsky, J. (2022). Recalibrating the scope of scholarly publishing: A modest step in a vast decolonization process. *Quantitative Science Studies*, 3(4), 912–930.
10. Kettl, D.F. *Sharing Power: Public Governance and Private Markets*; Brookings Institution Press: Washington, DC, USA, 2011.
11. Statista. 5G—Statistics & Facts. 2025. Available online: <https://www.statista.com/topics/3447/5g/?srsltid=AfmBOoqwLz1PwaNuxcOGXpe4chSvyttaEnxiMFzNriHlbev7lneexh-> (accessed on 24 June 2026).

12. Zheng, M.; Zhang, J.; Zhan, C.; Ren, X.; Lü, S. Proximal Policy Optimization with Reward-Based Prioritization. *Expert Syst. Appl.* 2025, 283, 127659.
13. Barth, M.; Boriboonsomsin, K. Real-world Carbon Dioxide impacts of traffic congestion. *Transp. Res. Rec.* 2008, 2058, 163–171.
14. Ajzen, I. The theory of planned behavior. *Organ. Behav. Hum. Decis. Process.* 1991, 50, 179–211.
15. Aung, P.S.; Nguyen, L.X.; Tun, Y.K.; Han, Z.; Hong, C.S. Aerial STAR-RIS Empowered MEC: A DRL Approach for Energy Minimization. *IEEE Wirel. Commun. Lett.* 2024, 13, 1409–1413.
16. Huang, C.; Yi, H.; Chen, T.; Xu, X.; Chen, S. Networked environmental governance: Formal and informal collaborative networks in local China. *Policy Stud.* 2022, 43, 403–421.
17. Cho, Y.J.; Wang, J.; Joshi, G. Client Selection in Federated Learning: Convergence Analysis and Power-of-Choice Selection Strategies. *arXiv* 2020, arXiv:2010.01243.
18. Kim, K.M. A study on the promotional activities and information provision by support centers for childcare: Focused on the Years 2019–2023. *J. Converg. Cult. Technol.* 2024, 10, 357–365.